

# ICS904/CD2IC : Cell Design For Digital Integrated Circuits

L4: Design Automation

Yves MATHIEU
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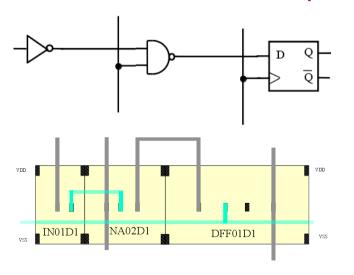
#### **Outline**

Standard cell libraries

Digital Integrated Circuit Testing

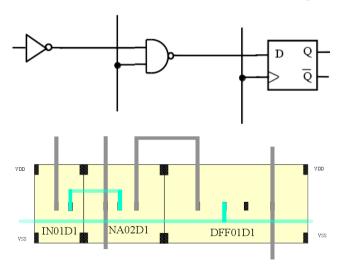
Place and route flow





- All cells have same height
- Power supply and Ground connected by abutment.
- Cell design should be free of DRC error.
- Any abutment of any couple of cells should be free of DRC error.
- Wiring inside cell limited to Metal1 level.

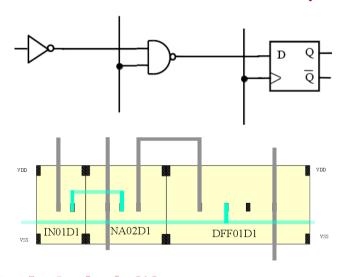




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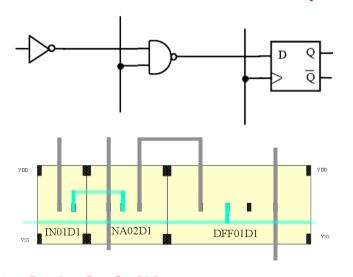


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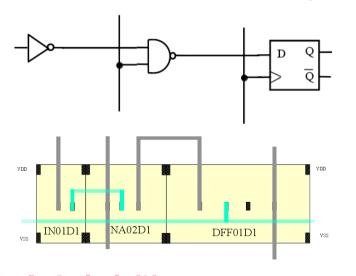




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Example: gsclib045 library based on gpdk045 technology

Cell category	Cell list
ADD	Full/Half adders, 2 outputs
AND	up to inputs
AO	AO/AOI up to 6 inputs
BUF	Buffers
FF	DFF (EN,SET,RST,QB)
INV	Invertor
MX	Multiplexor up to 4 inputs
NAND	up to 4 inputs
NOR	up to inputs
OA	OA/OAI up to 6 inputs
OR	up to 4 inputs
TLAT	Latches (SET,RST,)
XNOR	up to 3 inputs
XOR	up to 3 inputs

- A wide selection of cells
- Facilitate synthesis tools usage
- Non obvious cells



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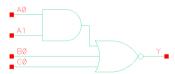
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Cell category	Cell list
ADD	X1,X2,X4
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AO	X2,X2,X4
BUF	X2,X3,,X16,X20
FF	X1,X2,X4,X8
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- No way to resize transistors
- Growing sizes of predefined output transistors
- Large choice for simple cells
- Small choice for complex cells
- Extra large choice for INV/BUF (load adaptation)



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- Several versions of the library with the same cell layout.
- Based on the available transistor threshold choice.
- A "Standard VT" version for general purpose logic.
- A low leakage version using "High VT" transistors but slower gates...
- A high speed version using "Low VT" transistors but more leakage...
- Synthesizer strategy :
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- During synthesis: clock signals are considered as ideal clocks, the designer defines expected clock properties (period, skew)
- Based on activity simulation, synthesis tool may insert "clock gating cells" in order to minimize power consumption
- During P&R phase, a clock tree is generated by the tools in order to full-fill the expected behavior. Specific **clock buffers**, with specific timing constraints are used (very short transition time)
- The P&R tool may insert "delay cells" in order to full-fill "hold timing" constraints (course between clk and data between D flip-flops
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- Physical only cells are cells that have no logic behavior. They are only needed by physical constraints of the layout
- Filler cells are used to fill holes between standard cells. This ensures, supply and well continuity.
- Well tap cells are used to connect Nwell and Pwell to the power supply and the ground.
- Antenna cells are used to limit the so called Antenna Effect during manufacturing
- **Decap cells** are used to limit ground and power bounce often called **IRdrop**.
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Refresh on Antenna Effect...

- During manufacturing phases, plasma etching leads to charge accumulation in conductor layers already created.
- If this layers are floating (not connected to drain/sources of transistors or wells) and connected to gates then gate oxide may break!!
- Place and route tools are able to evaluate and correct this problem :
- Evaluation: estimate the risk of breakdown, based on areas of metal/gates/implants connected to the conductor.
- Correction1 : Add and connect specific diodes (Antenna cells) in order to avoid floating layers during manufacturing
- Correction2: Modify routing in order to connect long lines of metal only during the last steps of manufacturing.



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Digital Integrated Circuit Testing

Place and route flow



- Filtering out defective devices during manufacturing.
- The more you wait to detect defaults, the more it costs.
- Test done at wafer level and after packaging.
- **Specification oriented test**: check the conformance to design specification.
- Application oriented test : check that the device works properly in its application environment.
- **Structural test**: check that there is no physical defect in the chip.
- Structural test is the more efficient et more easy to implement with generic methods.



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- Hard shorts, Hard open.
- Resistive bridges. Resitive shorts.
- Wiring defects. Component (transistors) defects.
- A fault is an undesired behaviour of a chip as a result of a defect
- fault models should :

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  - Represent defects that are typical for the technology used.
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#### The "stuck-at" fault model

- We assume that the only effect of a defect is a node that is stuck at low or high logic level.
- We assume that there is only one "stuck-at" fault in the circuit.
- All the remaining circuit may be used to test if this fault exists.
- How to detect a stuck-at "0" at node between G1 and G3?
- Controllability
- Try to put "1" on faulty node.
- Put "1" at G1 output
- Put "1,1" at G1 inputs

- G3 used to transmit value.
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#### The "stuck-at" fault model

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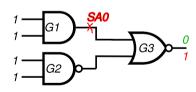
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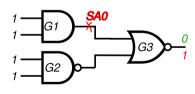


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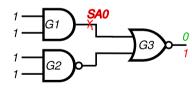


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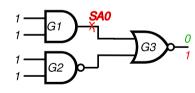


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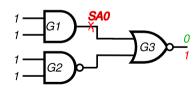
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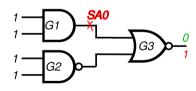


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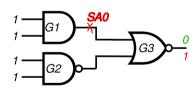
13/39

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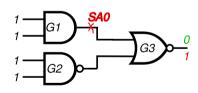


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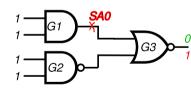


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- Usable for any combinational block based on simple combinational gates.
- Inputs are called primary inputs
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- For any combinational netlist algorithmic tools can compute a **test program**:
  - · The test program is a set of test vectors
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- A 100% stuck-at fault coverage can be achieved.



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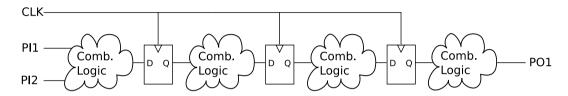
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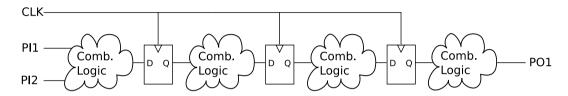
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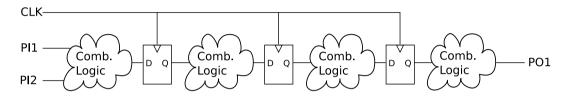
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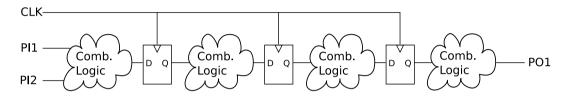
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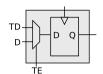
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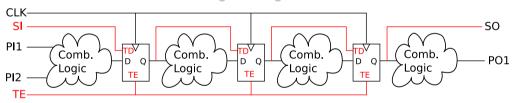


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- Scan DFF are chained in a long shift register.

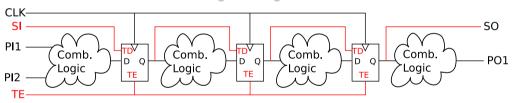


- A new SI serial input is used for controllability.
- A new SO serial output is used for observability.
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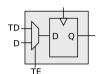


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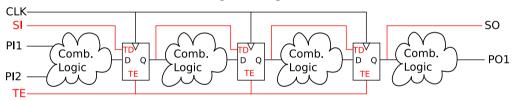


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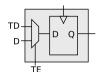
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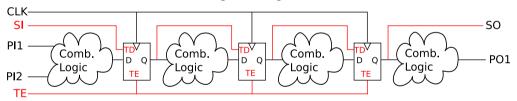


#### Scan Flip-Flop and Scan-chain



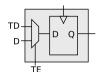
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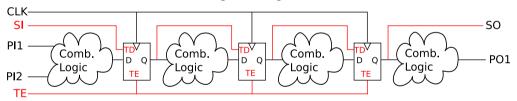


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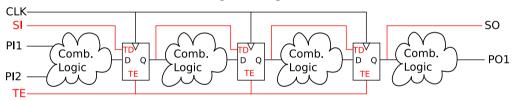


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# **Outline**

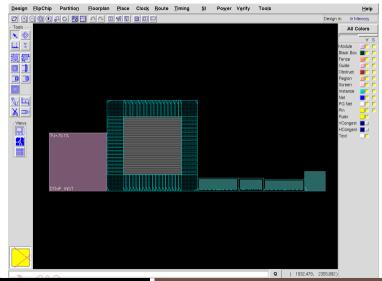
Standard cell libraries

Digital Integrated Circuit Testing

Place and route flow

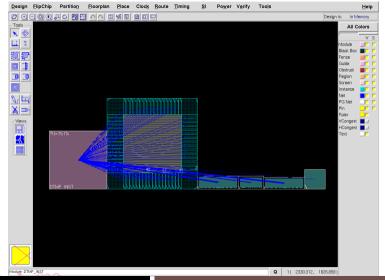


## SoC Encounter tool gui.



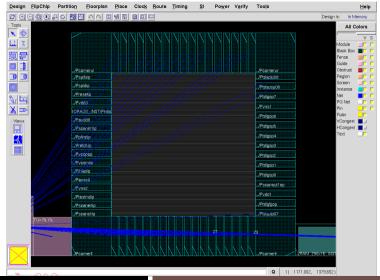


### Viewing nets as elastic wires.



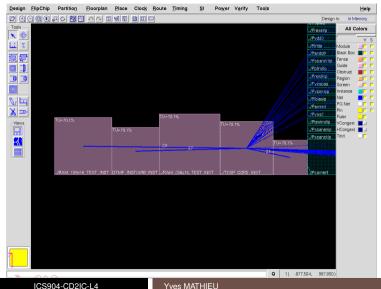


### Pads around de core, Corner pads.



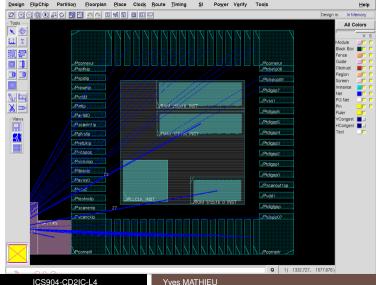


# The design hierarchy is preserved in the netlist



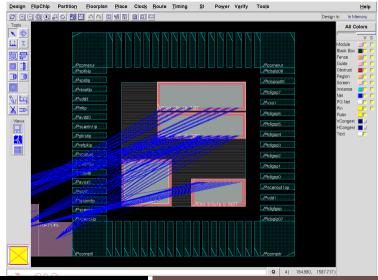


## Floorplan: Placement of macro-cells w/o power rings



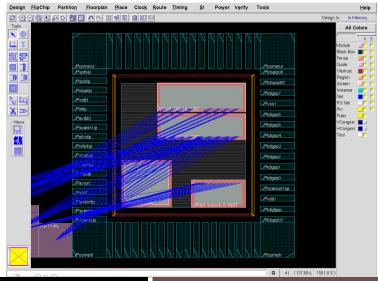


## Floorplan: Defining prohibited areas for standard cells



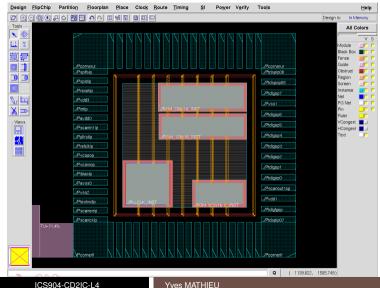


### Floorplan: Defining a global power ring



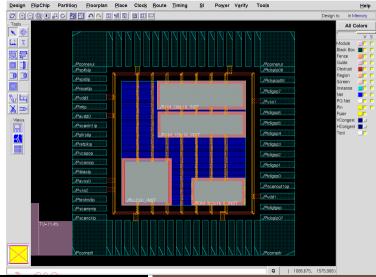


## Floorplan: Routing reinforcement power stripes



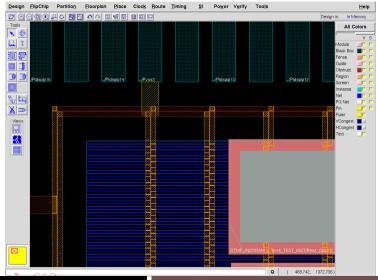


# Floorplan : Connecting Standard Cell Raws and Power pads



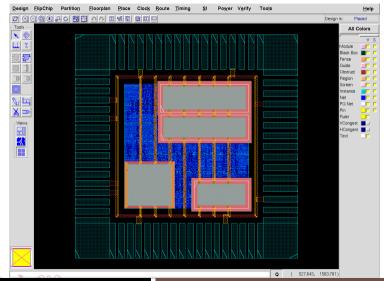


# Connection between lines uses arrays of standard size vias.



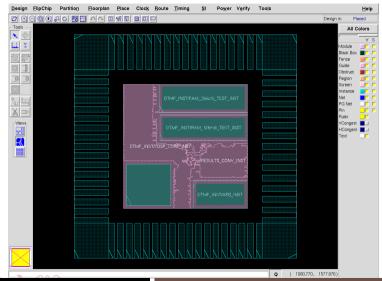


## **PLACEMENT**: Automatic placement of standard cells.



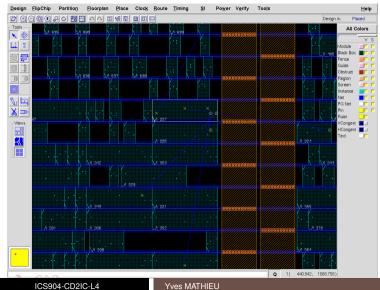


## **PLACEMENT**: Hierarchy analysis, placement guides.



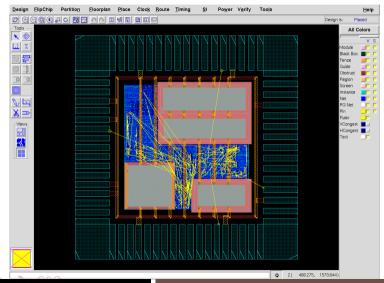


#### **PLACEMENT: Details.**



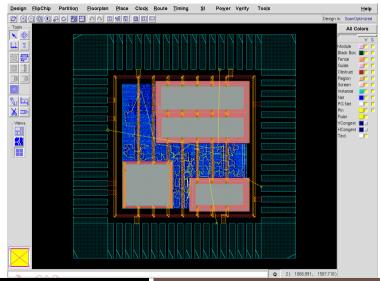


#### Initial SCAN chain for test



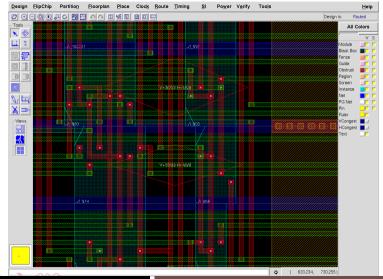


### Optimized restructured scan chain



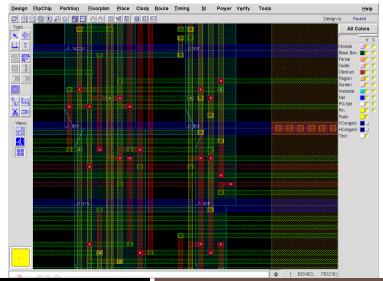


## Trial routing: not enough metal levels



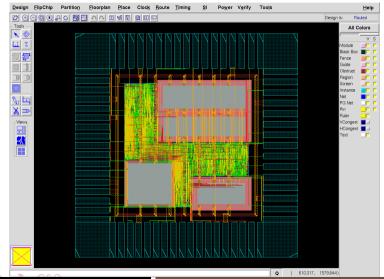


# Trial routing: better results with 6 levels





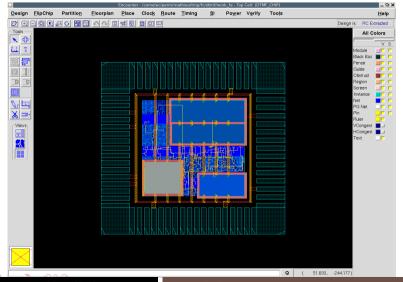
## Trial routing: the full circuit





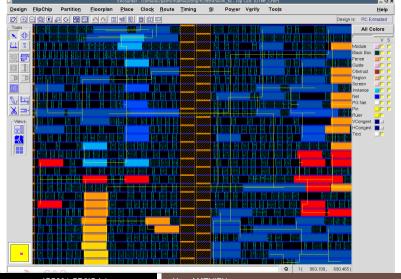
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### Clock tree synthesis: the tree of buffers





## Clock tree synthesis: Skew evaluation on CLK DFF inputs





## In place optimization and final routing with clock tree

